

NEWS RELEASE

Hitachi High-Tech

HITACHI

Hitachi High-Technologies Corporation

24-14, Nishi-shimbashi 1-chome, Minato-ku, Tokyo 105-8717, JAPAN

September 27, 2010

Notice of Patent Infringement Lawsuit against FEI Japan

On September 22, 2010, Hitachi High-Technologies (Tokyo: 8036, Hitachi High-Tech) filed suit in the Tokyo District Court to request the payment of damages related to the infringement by FEI Japan of focused ion beam technology patents held by Hitachi High-Tech. This latest suit involves separate patent rights than those highlighted on July 29, 2010, when the Company previously filed suit against FEI Japan for damages related to patent infringement. *

Hitachi High-Tech also filed for an injunction in the Tokyo District Court on November 6, 2009 to halt further patent infringement. ** This injunction is currently under litigation.

*Notice of Patent Infringement Lawsuit against FEI Japan

(News release on July 30, 2010)

<http://www.hitachi-hitec.com/global/whatsnew/2010/nr20100730.pdf>

**Notice of Patent Infringement Lawsuit against FEI Japan

(News release on November 6, 2009)

http://www.hitachi-hitec.com/global/whatsnew/2009/20091106_2.pdf

Reference

Notice Regarding Injunction against the Import of FIB/SEM Equipment from FEI Company

(News release on June 30, 2010)

<http://www.hitachi-hitec.com/global/whatsnew/2010/nr20100630.pdf>

Media Inquiries:

Public & Investor Relations Group, Secretary's Office

Aiko Matsumoto

Tel: +81-3-3504-3258